

2812



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Hideto Ohnuma et al.

Art Unit : 2812

Serial No. : 09/925,512

Examiner : Unknown

Filed : August 10, 2001

Title : METHOD OF MANUFACTURING A SEMICONDUCTOR DEVICE

#51IDS  
12/5/01  
V. Vannale

Commissioner for Patents  
Washington, D.C. 20231

**INFORMATION DISCLOSURE STATEMENT**

Applicants submit the references listed on the attached form PTO-1449, copies of which are enclosed.

Submitted herewith is an English translation of the following foreign language references, or portions thereof:

Desig. ID	Source
AM	Japan 2001-94113; Derwent File 352; WPI Accession No. 2000-341829/2000030 and EP 1 003 223 A2 (patent family)

This statement is being filed within three months of the filing date of the application and before the receipt of a first Office action on the merits. Please apply any charges or credits to Deposit Account No. 06-1050.

Respectfully submitted,

Date: November 8, 2001

  
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Substitute Form PTO-1449 (Modified)	U.S. Department of Commerce Patent and Trademark Office	Attorney's Docket No. 12732-068001	Application No. 09/925,512
<b>Information Disclosure Statement by Applicant</b> (Use several sheets if necessary) (37 CFR §1.98(b))		Applicant Hideto Ohnuma et al.	
		Filing Date August 10, 2001	Group Art Unit 2812

U.S. Patent Documents							
Examiner Initial	Design ID	Patent Number	Issue Date	Patentee	Class	Subclass	Filing Date If Appropriate
	AA						
	AB						
	AC						
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						
	AJ						
	AK						

Foreign Patent Documents or Published Foreign Patent Applications								
Examiner Initial	Design ID	Document Number	Publication Date	Country or Patent Office	Class	Subclass	Translation	
							Yes	No
	AL	EP 1 003 223	05/24/2000	Europe	H01L	29/786	N/A	
	AM	2001-94113	04/06/2001	Japan	H01L	29/786	XX	
	AN							
	AO							
	AP							

Other Documents (include Author, Title, Date, and Place of Publication)		
Examiner Initial	Design ID	Document
	AQ	
	AR	
	AS	
	AT	

Examiner Signature	Date Considered
EXAMINER: Initials citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.	